

3D-Nanoprinting of advanced high-resolution Magnetic Force Microscopy Tips



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Introduction



Figure 1: Focused Electron Beam Induced Deposition (FEBID) ogy

Magnetic devices are used in a various fields, ranging from sensing to data storage. The ongoing trend towards smaller feature sizes raises demand of analyzing magnetic features at the nanoscale. This examination can be conducted using Magnetic Force Microscopy (MFM), which has evolved into a powerful characterization technology that requires high-resolution MFM tips. In industry, magnetic sensitivity of AFM tips is achieved by additional coating which limits the resolution and brings the risk of local delamination. To overcome these limitations, the additive direct-write fabrication of magnetic nano-cones via focused electron beam induced deposition (FEBID) is introduced (Fig. 1).^[1] FEBID allows the modification or even full growth of functional AFM tips (Fig. 2).



n to full g



rigure 3: Dimerent patterning designs are snown, (a) ingle pillar deposited using a stationary e-beam. (b) Hollow cone design is printed in a circular pattern. (c) for the α-pillar a subsquent beam blur is applied to the static e-beam. (d) The MFM α-pillar is compared with a commercial coated MFM tip.^{(4),[5]} Holic

A HCo₃Fe(CO)₁₂ precursor was used for the full growth of MFM tips.[3] First, different patterning designs (Fig. 3) were explored to fulfill the strong demands for stable MFM operation. Then morphology, chemistry and structure were investigated over a wide range of patterning parameters. $Co_3Fe \alpha$ -pillars deposited at higher primary electron energies are

(a)

Figure 7: Comparison of MFM-Phase images of (a) a CoPt multilayer sample and (b) a magnetic hard disc drive.^{[5],[6]}

Heiaht

Morphology, Chemistry and Structure



Figure 4: TEM characteri-zation of Co₃Fe pillars. (a) TEM image, (b) high-pass filtered TEM-HAADF image 20 keV/81 pA α-pillar, (c) Scanning-TEM EDX map.^[5]

MFM Performance



igure 5: (a) SEM images of Co₃Fe α-pillars deposited at differ ent primary electron energies and beam currents (at high beam currents in upper row and low beam currents in lower row). (b) shows measured apex radii (top) and base widths (bottom) of α-pillars for different beam currents at a primary ectron energy of 20 keV.^[5]



Figure 6: Comparison of N CoPt multilayer sample e on of MFMample executed using a well-nercial MFM tip (MESP, Bruker) and a FEBID Co₃Fe α-pill

The MFM Phase images recorded with a wellestablished commercial MFM tip were compared with a FEBID Co₃Fe α -pillar for a CoPt multilayer sample^[6] (Fig. 6) and a hard disk drive (Fig. 7), revealing a superior AFM/MFM performance of the FEBID tip. Additionally, the wear resistance (Fig. 8) and the long term durability (Fig. 9) were tested, demonstrating a high wear resistance and practically no signal loss after 1 year of storage.

References

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(b)

tip (Fig. 3d).

Figure 8: Wear test experiments of the Co₂Fe α -pillars were carried ou continuously for almost 8 hours using a CoPt multilayer sample, which corresponds to a scanning distance of 46 cm. A comparison of the first and that (a) height make images is shown. High-quality MFM phase images is shown. High-quality MFM phase images (see green-framed box) were taken at lower scanning speed.^{[5],[6]}

Figure 9: The long term durability of Co₂Fe α-pillars was examined after 52-weeks of storage in ambient conditions. As can be seen, there is practically no loss of signal strength, image quality, or noise, which proves the chemical long-time stability of such 30 nano-probes. The

ding average phase shifts.

Conclusion

(a)

This work introduces all-metal Co₃Fe nano-probes for AFM-based magnetic force microscopy, fabricated by focused electron beam induced deposition. To provide mechanical rigidity, a special conical design is introduced, which is realized by gradual electron beam blurring. In comparison with well-established commercial products, optimized Co₂Fe α pillars reveal slightly lower absolute phase shifts, however, with very low noise and high lateral resolution for clear imaging of magnetic nano-features, which cannot be observed with commercial MFM probes.

Acknowledgements



Special thanks go to the FELMI-ZFE team. in particular to the work group of Prof. Plank.



